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APPLICATION NO. FILING		ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/629,678	,	07/30/2003	Junji Kunisawa	2003_1074	6560
513	7590	12/06/2004	EXAMINER		
WENDER 2033 K STI		ND & PONACK,	PERRIN, JOSEPH L		
SUITE 800		•	ART UNIT	PAPER NUMBER	
WASHING	TON, DC	20006-1021	1746		

DATE MAILED: 12/06/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary		Ар	plication No.	Applicant(s)			
		10	/629,678	KUNISAWA ET AL.			
Office Action Summary			aminer	Art Unit			
			eph L. Perrin, Ph.D.	1746			
Period fo	The MAILING DATE of this commun or Reply	ication appears	on the cover sheet with the c	orrespondence address			
THE - Exte after - If the - If NO - Failu Any	ORTENED STATUTORY PERIOD F MAILING DATE OF THIS COMMUN nsions of time may be available under the provisions 'SIX (6) MONTHS from the mailing date of this comn e period for reply specified above is less than thirty (3 D period for reply is specified above, the maximum st ure to reply within the set or extended period for reply reply received by the Office later than three months a ed palent term adjustment. See 37 CFR 1.704(b).	ICATION. of 37 CFR 1.136(a). nunication. i0) days, a reply withir atutory period will app will, by statute, cause	In no event, however, may a reply be tin the statutory minimum of thirty (30) day ly and will expire SIX (6) MONTHS from the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. 6 133)			
Status	-						
1)	Responsive to communication(s) file	ed on 29 Octobe	er 2004.				
		2b)☐ This action					
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Dispositi	ion of Claims						
5)□ 6)⊠ 7)⊠	Claim(s) <u>1-13</u> is/are pending in the a 4a) Of the above claim(s) <u>2-4 and 9-</u> Claim(s) is/are allowed. Claim(s) <u>1 and 5-8</u> is/are rejected. Claim(s) <u>1 & 13</u> is/are objected to. Claim(s) are subject to restrict	12 is/are withdr					
Applicati	on Papers						
9)[The specification is objected to by the	e Examiner.					
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).							
11)[The oath or declaration is objected to	by the Examin	er. Note the attached Office	Action or form PTO-152.			
Priority u	nder 35 U.S.C. § 119						
a)[Acknowledgment is made of a claim of All b) Some * c) None of: 1. Certified copies of the priority of None of: 2. Certified copies of the priority of None of: 3. Copies of the certified copies of the application from the Internation of the attached detailed Office action	documents have documents have of the priority do nal Bureau (PC	e been received. e been received in Application cuments have been received T Rule 17.2(a)).	on No d in this National Stage			
Attachment	(e)						
1) 🔲 Notice	e of References Cited (PTO-892)		4) Interview Summary (PTO-413)			
2)	e of Draftsperson's Patent Drawing Review (Pination Disclosure Statement(s) (PTO-1449 or Final)/Mail Date		Paper No(s)/Mail Dat 5) Notice of Informal Pa 6) Other:	e			
Patent and Tre	ordemark Office						

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DETAILED ACTION

Response to Arguments

1. In view of applicant's amendment filed 29 October 2004, the status of the application is as follows:

35 U.S.C. §102(b) Rejections over Yamagata & Toyokura The rejection of claims 1 & 5-7 are maintained for reasons set forth below. Applicant argues the prior art references do not disclose or suggest "a holder and a vacuum suction member that, with a substrate, define a space which can be purged by blowing N₂ gas thereinto so that etchant is prohibited from entering into the space during [processing] of the substrate." This is not persuasive because applicant's added limitation is directed to intended use rather than structure, intended use being given little patentable weight in apparatus claims. It has been held that a recitation with respect to the manner in which a claimed apparatus is intended to be employed does not differentiate the claimed apparatus from a prior art apparatus satisfying the claimed structural limitations. Ex parte Masham, 2 USPQ2d 1647 (1987). Since both Yamagata & Toyokura each "define a space", the space being fluidly sealed with respect to the space outside the holder, the position is taken that the structure of the references read on the structural limitations of the apparatus as claimed.

35 U.S.C. §103(a) Rejections over Yamagata in view of Sekine

The rejection of claim 8 is maintained for reasons of same set forth above.

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Claim Objections

2. Claim 1 is objected to because of the following informalities: In line 8, there appears to be a typographical error. The term "precessing" should be "processing". Appropriate correction is required.

Claim Rejections - 35 USC § 102

- 3. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.
- 4. Claims 1 & 5-7 are rejected under 35 U.S.C. 102(b) as being anticipated by US 5,951,833 to Yamagata. Re claim 1, Yamagata discloses a substrate holding unit with a holding plate (102) and vacuum suction members (104) contacting only the outer periphery of the substrate (101), thereby defining "a space" sealed from one side of the substrate (see, for instance, col. 10, line 54 col. 11, line 30; Figure 1). Re claim 5, Yamagata further discloses the holding unit in combination with a surface processing unit (anodizing apparatus, see, col. 2, line 56 et seq.). Re claim 6, Yamagata further discloses using the holding unit and surface processing unit with a cleaning apparatus and/or a drying apparatus (see, col. 4, lines 1-6). Re claim 7, Yamagata further discloses using a dipping bath (see, col. 7, line 21, as well as Figure 1 and relative associated text). Recitation of Yamagata reads on applicant's claimed invention.
- 5. Claim 1 is rejected under 35 U.S.C. 102(b) as being anticipated by JP 03242919 to Toyokura *et al.* (hereinafter "Toyokura"). Toyokura discloses (for instance, in Figure 7 and relative associated text) a substrate holding unit

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including a holding plate (8) and a vacuum suction member (12) contacting only the outer periphery of the wafer, thereby defining "a space" sealed from one side of the substrate. Recitation of Toyokura reads on applicant's claimed invention.

Claim Rejections - 35 USC § 103

- 6. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.
- 7. Claim 8 is rejected under 35 U.S.C. 103(a) as being unpatentable over Yamagata in view of US 5,660,744 to Sekine et al. (hereinafter "Sekine"). Recitation of Yamagata is repeated here from above. Although Yamagata does disclose etching a substrate in surface processing of a substrate (see, for instance, col. 10, lines 36-38), Yamagata does not disclose using an evaluation unit operable to check a condition of the surface of the substrate after processing to determine a resultant condition. Sekine teaches that it is known to provide a substrate processing apparatus, particularly an etching apparatus, with an evaluation unit (laser detector 51) to "measure etching depth" of the surface of a processed wafer (see, for instance, col. 20, lines 59-61). Therefore, the position is taken that a person of ordinary skill in the art at the time the invention was made would have been motivated to modify the substrate processing apparatus of Yamagata, which discloses etching, with the evaluation unit for detecting etching depth resultant from an etching process as disclosed by Sekine, for the purpose of more accurately achieving the desired degree of processing on a substrate.

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Allowable Subject Matter

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8. Claim 13 is objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

9. The following is a statement of reasons for the indication of allowable subject matter: The prior art of record does not teach or suggest the claimed holder plate having a purging aperture for blowing N₂ gas into the space defined by the holder plate, vacuum suction member, and the substrate.

Conclusion

- 10. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).
- 11. A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.
- 12. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Joseph L. Perrin, Ph.D. whose telephone

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number is (571)272-1305. The examiner can normally be reached on M-F 7:00-4:30, except alternate Fridays.

- 13. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael E. Barr can be reached on (571)272-1414. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.
- 14. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Joseph L. Perrin, Ph.D. Examiner Art Unit 1746

Shein

jlp